Search Notes



| Application/Control No. | Applicant(s)/Patent Under Reexamination |
|-------------------------|---|
| 10677112 | HOFMANN ET AL. |
| Examiner | Art Unit |
| Liu, Lin | 2145 |

| SEARCHED | | | | | | | | |
|----------|-----|----------|-------------|----------|--|--|--|--|
| Class | | Subclass | Date | Examiner | | | | |
| 709 | 237 | | 06/08/2007. | LL | | | | |

| SEARCH NOTES | | | | |
|---|------------|----------|--|--|
| Search Notes | Date | Examiner | | |
| Text search of USPAT, USPGPUB, EPO, JPO, DERWENT, IBM_TDB, see search history printout. | 06/08/2007 | L.L | | |
| Limited classified search of 709/232, 236, 237 | 06/14/2007 | L.L | | |
| L1: 709/237.ccls. and (@ad<20021213) reviewed consicely | 06/08/2007 | L.L . | | |
| 709/237.ccls. not L1, reviewed cursory. | 06/08/2007 | L.L | | |
| Diaglog search attached | 06/15/2007 | L.L | | |

| INTERFERENCE SEARCH | | | | | | |
|---------------------|----------|------|----------|--|--|--|
| Class | Subclass | Date | Examiner | | | |

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